

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Yoram Uziel et al.

Application No.

09/721,167

Filed:

November 22, 2000

For:

IN SITU MODULE FOR PARTICLE

REMOVAL FROM SOLID-STATE

SURFACES

Examiner:

Deven M. Collins

Group Art Unit: 2823

Attorney Docket No. STC-38090

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents Washington, D. C. 20231

Sir:

In response to the Requirement for Restriction dated 22 March 2002 in the above-identified application, the applicants hereby elect for further prosecution at the time the claims of Group II, i.e., claims 1 to 33, inclusive, drawn to an apparatus for removing particles from the surface of a substrate. This election is made without traverse.

Respectfully submitted,

April 22, 2002

Talivaldis Cepuritis (Reg. No. 20,818

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